Electronic Pate	ent App	lication Fe	Transm	ittal			
Application Number:	105	10588866					
Filing Date:	09-	09-Aug-2006					
Title of Invention:		POLYMER COMPOUND, PHOTORESIST COMPOSITION INCLUDING THE POLYMER COMPOUND, AND RESIST PATTERN FORMATION METHOD					
First Named Inventor/Applicant Name:	Tos	Toshiyuki Ogata					
Filer:	Nei	Neil S. Bartfeld/Jennifer Dolan					
Attorney Docket Number:	SHI	SHIGA7.053APC					
Filed as Large Entity	•						
U.S. National Stage under 35 USC 371 F	iling Fee	5					
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Basic Filing:					1		
Pages:							
Claims:							
Miscellaneous-Filing:							
Petition:							
Patent-Appeals-and-Interference:							
Post-Allowance-and-Post-Issuance:							
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